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A frequency selective surface (FSS) comprising a periodically 1 1. 2 replicated unit cell, the unit cell including a chemoresistive material having an electrical 3 conductivity that changes in a presence of an analyte. 4 The FSS of claim 1, wherein the unit cell further comprises an 1 2. arrangement of conducting patches on a dielectric substrate. 2 The FSS of claim 2, wherein at least two conducting patches are ı 3. interconnected by the chemoresistive material. 2 4. The FSS of claim 1, wherein the unit cell comprises a pattern of 1 chemoresistive material on a dielectric substrate. 2 The FSS of claim 1, wherein the unit cell includes at least one 5. 1 dielectric slot in a conducting medium, the chemoresistive material being adjacent to 2 3 the dielectric slot. The FSS of claim 1, wherein the chemoresistive material comprises a 1 6. conducting polymer. 2 The FSS of claim 1, wherein the electrical conductivity of the 7. 1 conducting polymer decreases when the conducting polymer is exposed to the analyte. 2 The FSS of claim 1, wherein the chemoresistive material includes a 8. 1 semiconductor nanostructure. 2 The FSS of claim 1, wherein the chemoresistive material includes a 9. 1 2 metal nanostructure.

The FSS of claim 1, wherein the chemoresistive material includes a

composite of a polymer and electrically conducting particles.

- 1 11. The FSS of claim 10, wherein the conducting particles are carbon-
- 2 containing particles.
- 1 12. The FSS of claim 10, wherein the polymer swells on exposure to the
- 2 analyte.
- 1 13. An artificial magnetic conductor comprising the FSS of claim 1, the
- 2 FSS being supported by a surface of a thin dielectric substrate, the opposed surface of
- 3 the dielectric layer supporting an electrical conductor.
- 1 14. An electromagnetic absorber including the FSS of claim 1.
- 1 15. An antenna including the FSS of claim 1.
- 1 16. An electromagnetic reflector including the FSS of claim 1.
- 1 17. A process for detecting an analyte, the process comprising:
- 2 providing an apparatus including a chemoresistive material, the
- 3 chemoresistive material having an electrical conductivity that changes on exposure to
- 4 the analyte;
- 5 determining an electromagnetic property of the apparatus, the electromagnetic
- 6 property being correlated with the electrical conductivity of the chemoresistive
- 7 material; and
- 8 detecting the analyte using the electromagnetic property.
- 1 18. The process of claim 17, wherein the electromagnetic property is a
- 2 electromagnetic transmission, electromagnetic absorption, or electromagnetic
- 3 reflection.
- 1 19. The process of claim 17, wherein the apparatus has a resonance
- 2 frequency, and the electromagnetic property is determined at the resonance frequency.

- 1 20. The process of claim 17, wherein determining the electromagnetic 2 property includes irradiating the apparatus with electromagnetic radiation from a 3 remote source of electromagnetic radiation.
- 1 21. The process of claim 17, wherein the remote source of electromagnetic radiation includes a radar transmitter.
- The process of claim 17, wherein the apparatus includes a frequency selective surface (FSS) comprising a periodically replicated unit cell, each unit cell including the chemoresistive material.
- The process of claim 22, wherein the FSS has a resonance frequency, the electromagnetic property being detected at the resonance frequency.
- 1 24. The process of claim 17, wherein the apparatus is deployed into the 2 atmosphere, and determining the electromagnetic property of the apparatus includes 3 irradiating the apparatus with a radar beam and detecting reflected radar radiation.
- 1 25. A frequency selective surface (FSS), the FSS comprising a periodically 2 replicated unit cell, the unit cell including a chemoresistive material having an 3 electrical conductivity that changes in a presence of an analyte.
- 1 26. The FSS of claim 25, wherein the unit cell has a geometry chosen so as 2 to provide an electromagnetic resonance at a resonance frequency.
- The FSS of claim 25, wherein the unit cell comprises an electrically conducting patch and a region of chemoresistive material adjacent to the electrically conducting patch.
- The FSS of claim 25, wherein the unit cell comprises a plurality of electrically conducting patches, and at least one region of chemoresistive material.

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The FSS of claim 25, wherein the unit cell comprises a first 29. 1 chemoresistive material having a first electrical conductivity correlated with a 2 presence of a first analyte, and a second chemoresistive material having an electrical 3 conductivity correlated with a presence of a second analyte. 4 The FSS of claim 25, wherein the unit cell includes at least one dipole 1 30. slot formed in a metal screen, and a region of chemoresistive material within the 2 3 metal screen. 1 The FSS of claim 30, wherein the region of chemoresistive material is 31. substantially adjacent to the at least one dipole slot. 2 An apparatus comprising a periodic structure, 32. 1 the periodic structure including a pattern of chemoresistive material, 2 the apparatus having a first electromagnetic property in a presence of an 3 analyte, and a second electromagnetic property in an absence of the analyte, 4 a difference between the first electromagnetic property and the second 5 electromagnetic property at least in part arising from an electrical conductivity change 6 of the chemoresistive material. 7 The apparatus of claim 32, wherein the periodic structure is a 33. l frequency selective surface supported on a surface of a dielectric layer. 2 The apparatus of 32, wherein the periodic structure further comprises a 34. l replicated pattern of metal patches. 2 The apparatus of claim 32, wherein the apparatus is an electromagnetic 1 absorber, electromagnetic reflector, electromagnetic transmitter, or antenna. 2

An apparatus including a frequency selective surface (FSS),

the FSS comprising a pattern of conductive patches,

- the conducting patches being selectively interconnectable by a matrix of independently addressable switches.
- 1 37. The apparatus of claim 36, wherein the switches are passive switches 2 not in electrical communication with a voltage source.
- 1 38. The apparatus of claim 37, wherein the switches are responsive to an external condition, the switches having a first electrical conductivity in a presence of the external condition, and a second electrical conductivity in an absence of the external condition.
- 1 39. The apparatus of claim 37, wherein the external condition is a presence 2 of an analyte, the switches having the first electrical conductivity in a presence of the 3 analyte, and the second electrical conductivity in an absence of the analyte.
- 1 40. The apparatus of claim 37, wherein the external condition is incident 2 electromagnetic radiation.
- 1 41. The apparatus of claim 36, comprising a plurality of switch types, each 2 switch type responsive to a different external condition.
- 1 42. The apparatus of claim 41, wherein each switch type is responsive to a different analyte.
- 1 43. An apparatus substantially as described herein.
- 1 44. A process of detecting an external condition substantially as described 2 herein.